2023년 2월 13일(월)~ 15일(수) | 강원도 하이원리조트(그랜드호텔 컨벤션타워)

2023년 2월 14일(화), 10:55-12:40 Room B (에메랄드 II+III, 5층)

D. Thin Film Process Technology 분과 [TB2-D] Thin Films Analysis

좌장: 이웅규 교수(숭실대학교), 김성근 책임연구원(한국과학기술연구원)

TB2-D-1 10:55-11:25 [초청]	Mono EELS Applications for Oxide and OLED and Atomic Level Imaging Denoising Method with Machine Learning Jae Hyuck Jang ^{1,2} ¹ Center for Electron Microscopy Research, KBSI, ² Graduate School of Analytical Science and Technology (GRAST)
TB2-D-2 11:25-11:55 [초청]	Visualizing Ultrathin Films Using Advanced Hard X-ray Scattering Techniques Seo Hyoung Chang Department of Physics, Chung-Ang University
TB2-D-3 11:55-12:25 [초청]	Probing Buried Interface with Hard XPS under Near-Total-Reflection Regime Deok-Yong Cho ^{1,2} ¹ Institute of Photonics, Electronics and Information Technology, Jeonbuk National University, ² Department of Physics, Jeonbuk National University
TB2-D-4 12:25-12:40	Measurement Technology of ALD Process based on Cocktail Precursor Replacing Super-cycle ALD Process Hayeong Kim ^{1,2} , Jiwon Park ^{1,3} , Jaeuk Lim ^{1,3} , SeonJeong Maeng ¹ , and Ju-Young Yun ^{1,4} ¹ Vacuum Materials Measurement Team, KRISS, ² Nanomaterials Science and Engineering, University of Science and Technology (UST), ³ Department of Advanced Materials Engineering, Daejeon University, ⁴ Nanoscience and Technology, University of Science and Technology (UST)